



PATENT  
81790.0211

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Koichi GEN-EI et al.

Serial No: 09/954,475 ✓

Filed: September 14, 2001

For: SEMICONDUCTOR LASER WHICH  
REMOVES INFLUENCES FROM  
RETURNING LIGHT OF THREE  
BEAMS AND METHOD OF  
MANUFACTURING THE SAME

Date of NOA: May 20, 2004

Art Unit: 2828

**TRANSMITTAL OF FORMAL DRAWINGS**

Attn: OFFICIAL DRAFTSPERSON  
Mail Stop ISSUE FEE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

I hereby certify that this correspondence  
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August 19, 2004  
Date of Deposit

Firoozeh Vakilzadeh

Name

Signature

Date

Dear Sir:

In response to the Notice of Allowance dated May 20, 2004, enclosed are the formal drawings (5 sheet(s) – Figure(s) 1-12B) in the above-captioned case. All the drawing changes have been made as requested in the Notice of Allowability.

The Commissioner is hereby authorized to charge any deficiency in payment or credit any overpayment to Deposit Account No. 50-1314. A copy of this Transmittal is enclosed.

Respectfully submitted,

HOGAN & HARTSON L.L.P.

By:

Lawrence J. McClure, Ph.D.  
Registration No. 44,228  
Attorney for Applicant(s)

Date: August 19, 2004

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